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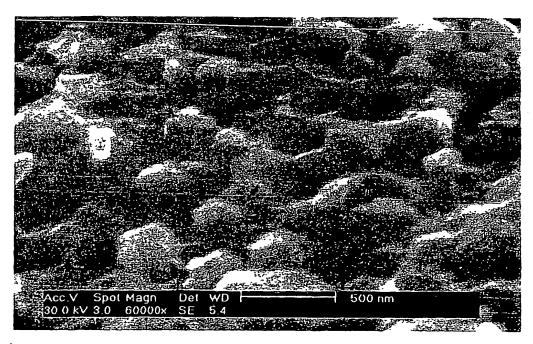
- (71) Applicant (for all designated States except US): ASTRA TECH AB [SE/SE]; Aminogatan 1, S-431 21 Mölndal (SE).
- (72) Inventors; and
- (75) Inventors/Applicants (for US only): PETERSSON, Ingela [SE/SE]; Godhemsgatan 22A, S-414 68 Göteborg (SE). JUNEMO-BOSTRÖM, Kristina [SE/SE]; Barefjällsgatan 3, S-415 06 Göteborg (SE). JOHANS-SON-RUDÉN, Gunilla [SE/SE]; Bergstigen 20, S-436 42 Askim (SE). ANDERSSON, Fredrik [SE/SE]; Brogatan

2B, S-431 30 Mölndal (SE). HANSSON, Stig [SE/SE]; Gåsmossen 32, S-436 39 Askim (SE).

- (74) Agent: AWAPATENT AB; Box 11394, S-404 28 Göteborg (SE).
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(54) Title: AN IMPLANT AND A METHOD FOR TREATING AN IMPLANT SURFACE



(57) Abstract: The invention relates to a method for treating an implant surface intended for implantation into bone tissue wherein a microroughness comprising pores and peaks having a pore diameter of $\leq 1 \, \mu m$, a pore depth of $\leq 500 \, nm$, and a peak width, at half the pore depth, of from 15 to 150 % of the pore diameter is provided. The invention also relates to an implant comprising a surface having the above characteristics.

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